

807737

| | | | | | |
|-----------------------------------|--|--------------------------------------|--|--------------------------------------|--|
| Notice of References Cited | | Application No. 08/479,211 | | Applicant(s) Ohtani et al. | |
| | | Examiner Leon Radomsky | | Group Art Unit 1104 | |
| Page 1 of 1 | | | | | |

| U.S. PATENT DOCUMENTS | | | | | |
|-----------------------|--------------|---------|--------------|-------|----------|
| | DOCUMENT NO. | DATE | NAME | CLASS | SUBCLASS |
| A | 5,529,937 | 6-25-96 | Zhang et al. | 437 | 21 |
| B | 5,481,121 | 1-2-96 | Zhang et al. | 257 | 64 |
| C | 5,219,786 | 6-15-93 | Noguchi | 437 | 174 |
| D | | | | | |
| E | | | | | |
| F | | | | | |
| G | | | | | |
| H | | | | | |
| I | | | | | |
| J | | | | | |
| K | | | | | |
| L | | | | | |
| M | | | | | |

| FOREIGN PATENT DOCUMENTS | | | | | | |
|--------------------------|--------------|------|---------|------|-------|----------|
| | DOCUMENT NO. | DATE | COUNTRY | NAME | CLASS | SUBCLASS |
| N | | | | | | |
| O | | | | | | |
| P | | | | | | |
| Q | | | | | | |
| R | | | | | | |
| S | | | | | | |
| T | | | | | | |

| NON-PATENT DOCUMENTS | | |
|----------------------|--|------|
| | DOCUMENT (Including Author, Title, Source, and Pertinent Pages) | DATE |
| U | S. Caune et al., Appl. Surf. Sci., 36(1989)597, "Combined CW laser and furnace annealing of amorphous Si and Ge in contact with some metals". | 1989 |
| V | M. Fuse et al., Solid State Phenomena, 37-38(1994)565, "Performance of poly-si TFTs fabricated by excimer laser annealing ... with or without solid phase crystallization" | 1994 |
| W | | |
| X | | |